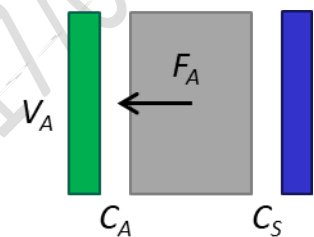


Question n. 1

The "C-V curve" method can be used to test a MEMS in the electromechanical characterization phase. Describe how this procedure is implemented (with applied signals at the different electrodes), how it can be related to a force-displacement graph, and which relevant electromechanical parameters can be extracted through this procedure. You can help yourself with equations and graphs, where useful.

The C-V curve is part of the so-called electromechanical characterizations, i.e. those characterization whose aim is the experimental validation of the electromechanical parameters of the design phase. In particular, the C-V curve is a quasi-stationary characterization in that it gives information on the low-frequency (DC) behavior of the MEMS. As a consequence, it can validate only those parameters which can be measured in a low-frequency range: typically, the stiffness, the DC offset and the pull-in voltage, while e.g. the resonance frequency and damping coefficient (Q factor) cannot be estimated with this method.

To implement a C-V curve one can use the scheme depicted aside, with an actuation voltage V_A applied at one port and the other port used as a capacitive sensor. A readout scheme that allows to measure DC capacitance variation caused by V_A (and by the corresponding force F_A) is reported in the second figure, and makes use of a high-frequency test signal $v_s(t)$, applied at the rotor, so that the current through the sense port $i_t(t)$ is dominated by the contribution $C_S dv_s/dt$ (linear with the sense capacitance) and not to $V_s(t) dC_S/dt$ (which is small as the capacitance change is quasi-stationary in time).



As the electrostatic force is quadratic with the applied voltage, and as the capacitance variation is (at a 1st-order approximation) linear with the displacement, the obtained curve is parabolic, with a negative slope (the rotor is attracted towards the actuator, and goes away from the sense stator). In terms of equation one can derive the expression reported below:

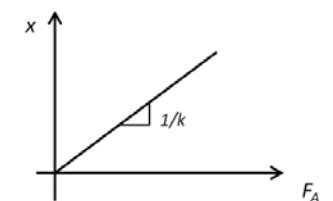
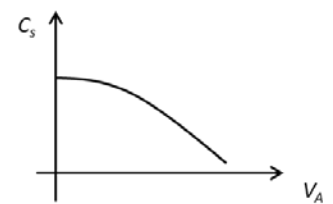
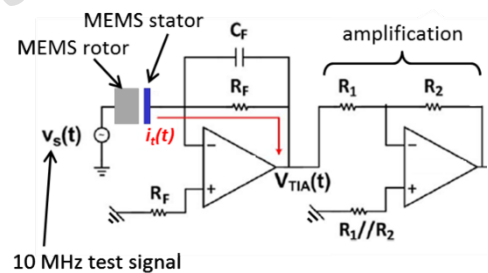
$$\Delta C_S = -\frac{C_S^2 V_A^2}{g^2 k 2} = -\frac{(\epsilon_0 A_{PP} N_{PP})^2 V_A^2}{g^4 k 2}$$

From the measured ΔC_S and from the two simple equations below:

$$|F_A| = \frac{V_A^2}{2} \frac{dC_A}{dx} \quad x = \frac{\Delta C_S}{\frac{dC_S}{dx}}$$

one can easily transform the measured C-V curve into a force-displacement plot, which will be a linear graph whose slope represents the device stiffness.

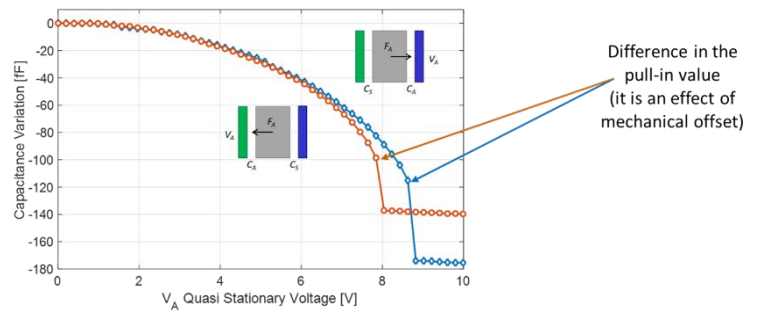
Note that in presence of mechanical offsets, the C-V curve can be also used to give an estimated of such offsets, simply repeating the measurement described above with inverted actuator and sensor ports.



A second parameter that can be easily estimated through a C-V curve is the pull-in voltage in parallel-plate configurations. Indeed, increasing the applied voltage, the structure will pass, for a specific voltage value, the critical condition of instability and the rotor will collapse towards the actuator.

This can be evidenced first by a deviation from the parabolic behavior (due to the no longer valid small-displacement approximation) and then by a sudden capacitance change (in particular, a decrease of the capacitance used as the sensing port).

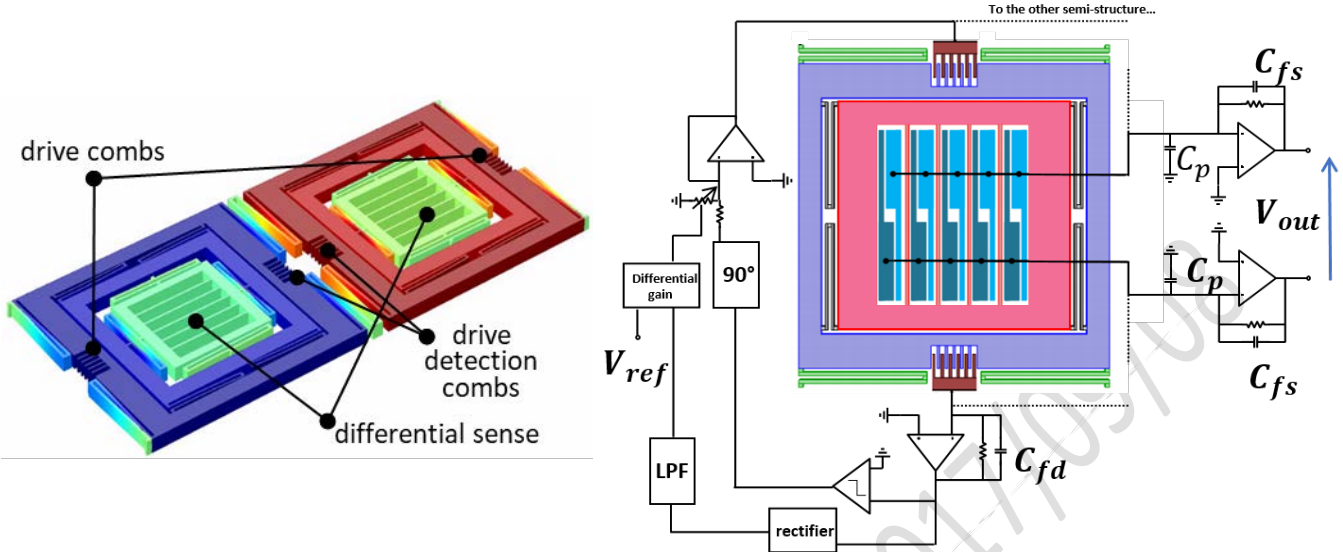
Again, the difference in the value of the measured pull-in voltage when exchanging sensor and actuator ports can be used as an indication to estimate the mechanical offset.



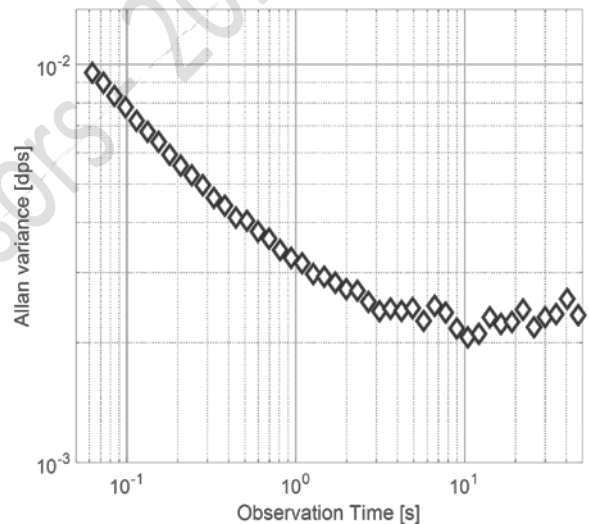
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Question n. 2

A tuning-fork Z-axis gyroscope operates in mode-split conditions with the parameters indicated in the Table.



Rotor bias voltage	V_{dc}	10	V
Drive detection fingers (½ structure)	N_{cf}	32	-
Process thickness	h	25	μm
Process gap	g	2.1	μm
Drive circuit feedback capacitance	C_{fd}	350	fF
Sense plate length	L_{pp}	350	μm
Sense circuit feedback capacitance	C_{fs}	1	pF
Differential PP cells (½ structure)	N_{pp}	5	-
Sense mode Q factor	Q_s	100	-
Sense mass (half structure)	m_s	2	nkg
Opamp voltage noise density	S_{Vn}	10	nV/ $\sqrt{\text{Hz}}$
Parasitic capacitance	C_p	10	pF
Sense mode resonance frequency	$f_{0,s}$	20	kHz



- 1) evaluate the voltage V_{ref} in the figure, in order to obtain a controlled drive displacement of $\pm 5 \mu\text{m}$;
- 2) evaluate the overall sensitivity (in [V/dps]), making reasonable design assumptions to guarantee a flat bandwidth of about 200 Hz;
- 3) evaluate the overall, input-referred white noise density (in [dps/ $\sqrt{\text{Hz}}$]);
- 4) verify the white noise density measured through the Allan curve given above, and evaluate the 1/f noise coefficient.

Physical Constants

- $q = 1.6 \cdot 10^{-19} \text{ C}$
- $k_b = 1.38 \cdot 10^{-23} \text{ J/K}$
- $T = 300 \text{ K}$ (if not specified)
- $\epsilon_0 = 8.85 \cdot 10^{-12} \text{ F/m}$

We know that the AGC, through a negative feedback loop, forces the LPF output voltage to be equal to the external V_{ref} . This voltage can be properly set in order to obtain the desired oscillation amplitude: in this case, we want $x_D = 5\mu\text{m}$. Such a displacement generates a motional current equal to:

$$i_m = \eta_{DD} \cdot v_D = \eta_{DD} \cdot \dot{x}_D = 2 \cdot \frac{2\epsilon_0 H N_{cf}}{g} V_{DC} \cdot \omega_D \cdot x_D$$

This current will flow in the drive-detection TCA feedback capacitance, causing an output voltage equal to:

$$V_{out,TCA} = i_m \cdot \frac{1}{\omega_D C_{fd}} = 2 \cdot \frac{2\epsilon_0 H N_{cf}}{g} V_{DC} \cdot x_D \cdot \frac{1}{C_{fd}} = 1.92 \text{ V}$$

This voltage is rectified and then its mean value is extracted through a low-pass filter:

$$V_{ref} \sim V_{out,LPF} = \frac{2}{\pi} \cdot V_{out,TCA} = 1.22 \text{ V}$$

We know that, in mode-split operation with a fixed Δf_{MS} , the gyroscope bandwidth is flat for roughly $\frac{\Delta f_{MS}}{2} \div \frac{\Delta f_{MS}}{3}$. We can thus choose a $\Delta f_{MS} = 600 \text{ Hz}$ to guarantee a 200 Hz bandwidth.

We can now easily evaluate the sensitivity in term of [V/dps]:

$$S = \frac{dy}{d\Omega} \cdot \frac{dC}{dy} \cdot \frac{dV_{out}}{dC} = \frac{x_D}{\Delta\omega_{MS}} \cdot 2 \cdot \frac{2\epsilon_0 N_{pp} L_{pp} H}{g^2} \cdot \frac{V_{DC}}{C_{fs}} \cdot \frac{\pi}{180} = 81 \mu\text{V/dps}$$

First of all, the device intrinsic noise contribution can be evaluated. The damping coefficient is a missing data, but we can derive its value from the sense quality factor:

$$b_s = \frac{\omega_s(2 \cdot m_s)}{Q_s} = 5 \cdot 10^{-6} \text{ N/(m/s)}$$

So, we can easily evaluate the Noise Equivalent Rate Density:

$$NERD = \frac{180}{\pi} \cdot \frac{1}{x_D \omega_s m_s} \cdot \sqrt{K_b T b_s} = 3.3 \frac{\text{mdps}}{\sqrt{\text{Hz}}}$$

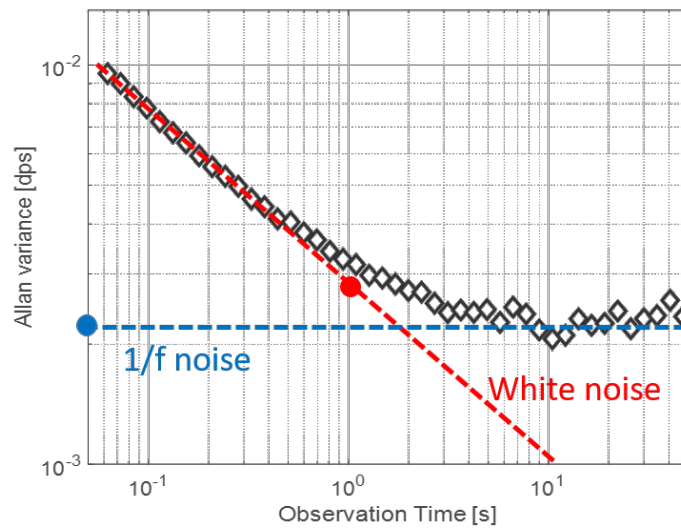
The contribution of electronic noise (supposing a sufficiently high value R_f with negligible noise) is given by:

$$\sqrt{S_{in,opamp}} = \frac{\sqrt{2 \cdot S_{vn}} \cdot (1 + C_p/C_f)}{S^2} = 1.9 \frac{\text{mdps}}{\sqrt{\text{Hz}}}$$

Thus, the overall input-referred white noise density is equal to:

$$\sqrt{S_{in,tot}} = \sqrt{NERD^2 + S_{in,opamp}} = 3.8 \frac{\text{mdps}}{\sqrt{\text{Hz}}}$$

We know that, in an Allan Variance plot, the graph portion with $-1/2$ slope is associated with the white noise density, while the flat portion is determined by the flicker noise. We can thus graphically evaluate the two contributions:



For what concerns the white noise:

$$\sqrt{S_{in,tot}} = \sqrt{2} \cdot \sigma_{AV}(\tau = 0) = \sqrt{2} \cdot 2.7 \frac{mdps}{\sqrt{Hz}} = 3.85 \frac{mdps}{\sqrt{Hz}}$$

The result is very similar to the theoretical calculation. Let's finally compute the 1/f noise (with power spectral density $\frac{\alpha_n}{f}$) coefficient:

$$\alpha_n = \frac{\sigma_{AV}^2}{2 \log 2} = 3.18 \cdot 10^{-6} \frac{dps^2}{Hz}$$

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Question n. 3

An imaging system is used in an industrial environment to monitor the quality of a product.

For this reason, the product, assumed to be an isotropic reflector with a 0.2 reflectance coefficient, square-shaped of 10-cm side, is illuminated with a light source (with average wavelength of 500 nm) so that the optical power impinging on the product is 107 mW.

The imaging system, composed of a lens and a 3T CMOS sensor, is placed 50 cm far from the product, orthogonal to the plane of the object.

The camera takes pictures of the object with a 10-ms integration time and an F number of 4.

Some sensor and pixel parameters are reported in the Table.

- 1) Evaluate the magnification factor and the required focal length in order to fit the object within the sensor.
- 2) Calculate the photon flux, expressed in photons/s/m², impinging on the sensor.
- 3) Calculate the required pixel size so that the signal-to-noise ratio of the pixel is 40 dB. Which is the dominant noise source?
- 4) Is the system diffraction limited?

Sensor width	15	mm
Sensor height	10	mm
Pixel supply voltage	1.8	V
Photodiode depletion region width	1	μm
Dark current density	0.1	aA/μm ²

Physical Constants

$$q = 1.6 \cdot 10^{-19} \text{ C}$$

$$k_b = 1.38 \cdot 10^{-23} \text{ J/K}$$

$$T = 300 \text{ K (if not specified)}$$

$$\epsilon_0 = 8.85 \cdot 10^{-12} \text{ F/m}$$

$$\epsilon_{Si} = 11.7 \epsilon_0$$

In order to fit the square-shaped object within the rectangular sensor, the required magnification factor can be evaluated as

$$m = \frac{H_{sens}}{H_{scene}} = 0.1$$

Hence, the focal length of the optics should be

$$f = d * m = 50 \text{ mm}$$

where d is the distance from the object to the lens (50 cm). The diameter of the lens, d_{lens} , is thus

$$d_{lens} = \frac{f}{F} = 12.5 \text{ mm}$$

The optical power reflected by the object is

$$P_R = R * P_I$$

where R is the reflectance coefficient, and P_I is the optical power impinging on the sensor. Since the reflection is isotropic, the power impinging on the lens, hence on the sensor, can be evaluated as

$$P_{sens} = P_R \frac{\Omega_{lens}}{2\pi} = RP_I \frac{A_{lens}}{d^2} = RP_I \frac{\pi \left(\frac{d_{lens}}{2}\right)^2}{2\pi} = 1.67 \mu\text{W}$$

The optical intensity (power / surface) can be found by dividing the power for the area of the sensor corresponding to the object, i.e., H_{sens}^2 . Hence,

$$I_{sens} = \frac{P_{sens}}{H_{sens}^2} = 16 \text{ mW/m}^2$$

As the average energy of one photon is

$$E_{ph} = \frac{hc}{\lambda} = 396 \times 10^{-21} \text{ J}$$

The photon flux can be evaluated as

$$\phi = \frac{I_{sens}}{E_{ph}} = 42 \times 10^{15} \frac{\text{photons}}{\text{s} \cdot \text{m}^2}$$

Targeting a 40 dB SNR, i.e., a SNR of 100, assuming that the system is shot noise limited, the required number of photons is

$$N_{ph} = SNR^2 = 10\,000$$

with an associated shot noise of

$$\sigma_{shot} = \sqrt{N_{ph}} = 100$$

Given the integration time, the required photon rate, n'_{ph} is

$$n'_{ph} = \frac{N_{ph}}{t_{int}} = 1\,000\,000 \frac{\text{photons}}{\text{s}}$$

The required pixel size is then

$$l_{pix} = \sqrt{\frac{n'_{ph}}{\phi}} = 4.8 \text{ } \mu\text{m}$$

Assuming a high fill factor (reasonable assumption with a 4.8 μm -sized pixel), $F \simeq 1$, the photodiode capacitance is

$$C_{PD} = \frac{\epsilon_{si} l_{pix}^2}{x_{dep}} = 2.4 \text{ fF}$$

The associated reset noise is

$$\sigma_{reset} = \frac{\sqrt{kTC_{PD}}}{q} = 20$$

negligible with respect to shot noise (remember that comparison should be done with variances, not with standard deviations). Also dark current shot noise is negligible (< 1 electron rms). The dominant noise source is, as expected, signal shot noise.

The Airy diameter can be evaluated as $d_{Airy} = 2.44 \cdot \lambda \cdot F = 4.8 \text{ } \mu\text{m}$. Resolution limit due to diffraction is thus comparable with the resolution due to spatial sampling.